

IN THE UNITED STATES
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APPLICATION NO.: 10/801,362

FILING DATE: March 15, 2004

TITLE: Inspecting Optical Masks With Electron Beam Microscopy

EXAMINER: Unknown

GROUP ART UNIT: 1756

ATTY. DKT. NO.: 22120-08965

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop Missing Parts, Commissioner For Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date shown below:

Dated: September 17, 2004

By:

Laura Majerus
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REQUEST FOR CORRECTED FILING RECEIPT

SIR:

Enclosed is a copy of the Official Filing Receipt. It contains the following errors:

1. The attorney docket number is erroneously stated as 4765. The correct attorney docket number is **22120-08965**, as evidenced by the first page of the Preliminary Amendment and New Utility Patent Application Transmittal, copies of which are enclosed.

2. The residence of applicant Surendra Lele is erroneously stated as Cupertino. The correct residence of applicant Surendra Lele is **Cupertino**, as evidenced by page 4 of the Declaration of the parent application, a copy of which is attached.

3. The above-referenced application is a continuation of pending serial no. 09/502,534, filed on February 10, 2000; the subject matter of the present reissue is related to co-ending reissue serial no. 09/502,120, filed on February 10, 2000. Serial nos. 09/502,534 and 09/502,120 are each a reissue application for patent no. 5,717,204 issued February 10, 1998 (application no. 08/606,854 filed February 26, 1996), which is a continuation of 08/252,763 which is a CIP of 07/889,460, as evidenced by the third page of the Preliminary Amendment filed March 15, 2004 in this matter, a copy of which is enclosed. This Filing Receipt should be corrected to indicate this missing Continuing Data.

Please issue a corrected Filing Receipt rectifying this error.

Respectfully submitted,
DAN MEISBURGER, ET AL.

Dated: September 17, 2004

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| APPL NO. | FILING OR 371 (c) DATE | ART UNIT | FIL FEE REC'D | ATTY. DOCKET NO | DRAWINGS | TOT CLMS | IND CLMS |
|------------|---------------------------|----------|---------------|-----------------|----------|----------|----------|
| 10/801,362 | 03/15/2004 | 1756 | 2124 | 4765 | 20 | 57 | 10 |

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AUG 16 2004

Received

CONFIRMATION NO. 4849

FILING RECEIPT



OC000000013440774

Date Mailed: 08/04/2004

Receipt is acknowledged of this reissue Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

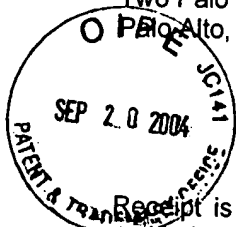
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Domestic Priority data as claimed by applicant

This application is a REI of 08/606,854 02/26/1996 PAT 5,717,204
 which is a CON of 08/252,763 06/02/1994 ABN
 which is a CIP of 07/889,460 05/27/1992 ABN

Foreign Applications

If Required, Foreign Filing License Granted: 08/04/2004



Projected Publication Date: None, application is not eligible for pre-grant publication

Non-Publication Request: No

Early Publication Request: No

Title

Inspecting optical masks with electron beam microscopy

Preliminary Class

430

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Title 35, United States Code, Section 184
Title 37, Code of Federal Regulations, 5.11 & 5.15**

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